



INFORMATION DISCLOSURE CITATION IN AN APPLICATION

(See several sheets if necessary)

Document Number (Continued)

TSMC-03-636

Application Number

10/812,729

Applicant

Hsien-Ping Feng et al.

Filing Date

03/30/04

Group Art Unit

U. S. PATENT DOCUMENTS

EXAMINER INITIAL	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	PURSUANT TO APPROPRIATE
Dh	6380084	4/30/02	Lim et al.	438	687	10/2/00
	6582569	6/24/03	Chiang et al.	204	192.17	10/19/00
	6077780	6/20/00	Dubin	438	687	12/3/97
	6245670	6/12/01	Cheung et al.	438	637	2/19/99
	6391777	5/21/02	Chen et al.	438	687	5/2/01
Dh	6350688	2/26/02	Liu et al.	438	687	8/1/00

FOREIGN PATENT DOCUMENTS

	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	Translation	
						YES	NO

OTHER DOCUMENTS (Including Author, Title, Date, Portion of Pages, Etc.)

Dh	* US Patent App. Publication US 2003/0140988 A1 to
	* Gandikota et al., Pub. Date 07/31/03, Filed 01/28/02,
	* US Cl. 148/527.

EXAMINER

Dh

DATE CONSIDERED

6/2005

EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP § 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to the applicant.